

## Electrosurface properties of silicon oxide(IV) in aqueous solutions of azoles

© Alexander S. Chukhno,<sup>+</sup> Irina B. Dmitrieva,\* Valeria A. Aksinovich,  
Daria S. Silaeva, Anna S. Senina, and Anton A. Kergentsev

*Department of Physical and Colloid Chemistry. St. Petersburg State Chemical-Pharmaceutical Academy.*

*Professor Popov St., 14. St. Petersburg, 197376. Russia.*

*Phone: +7 (812) 234-11-38. E-mail: alex-chuhno@yandex.ru, dasha.com.92@mail.ru*

\*Supervising author; <sup>+</sup>Corresponding author

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### Abstract

The paper is devoted to the study of electrosuperficial properties of quartz (silicon oxide(IV)) in aqueous solutions of simple azoles. To determine the electrokinetic properties of silicon oxide (SiO<sub>2</sub>) we used the method of micro-electrophoresis. Study of electrokinetic properties of SiO<sub>2</sub> surface was held over the function of pH and contact time with the phases of quartz test solutions. It has been found that in solutions of the isoelectric point value of imidazole (pH<sub>IET</sub>) of quartz shift to alkaline region. In solutions of *n*-tetrazole the value pH<sub>IET</sub> of quartz shifts in acidic region. This paper describes a model of adsorption of cationic and anionic forms of azoles on the surface of SiO<sub>2</sub>.